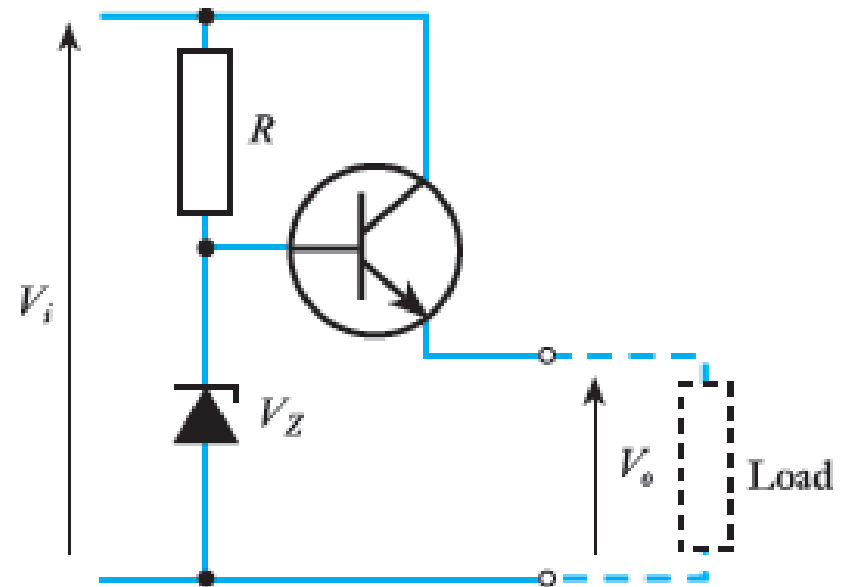
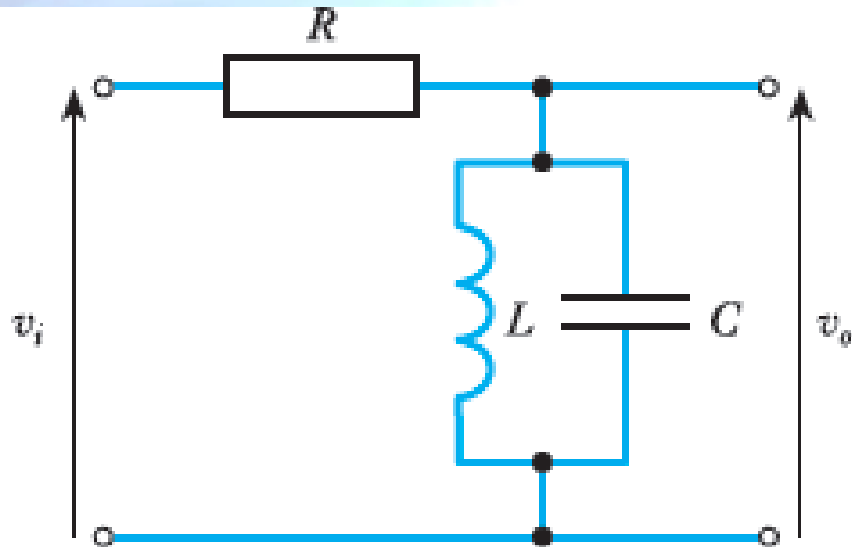


# Introduction to Semiconductors

*Dr. Lasith Yasakethu*

# Electrical Vs. Electronic Circuits

- What is the significant about electronic circuits?



# Electrical Vs. Electronic Circuits

- **The main difference:** electrical circuits have no decision making (processing) capability, whilst electronic circuits do
- An electric circuit simply powers machines with electricity. However, an electronic circuit can interpret a signal or an instruction, and perform a task to suit the circumstance
- Most modern appliances use a combination of electronic and electrical circuitry

# Electrical Vs. Electronic Circuits

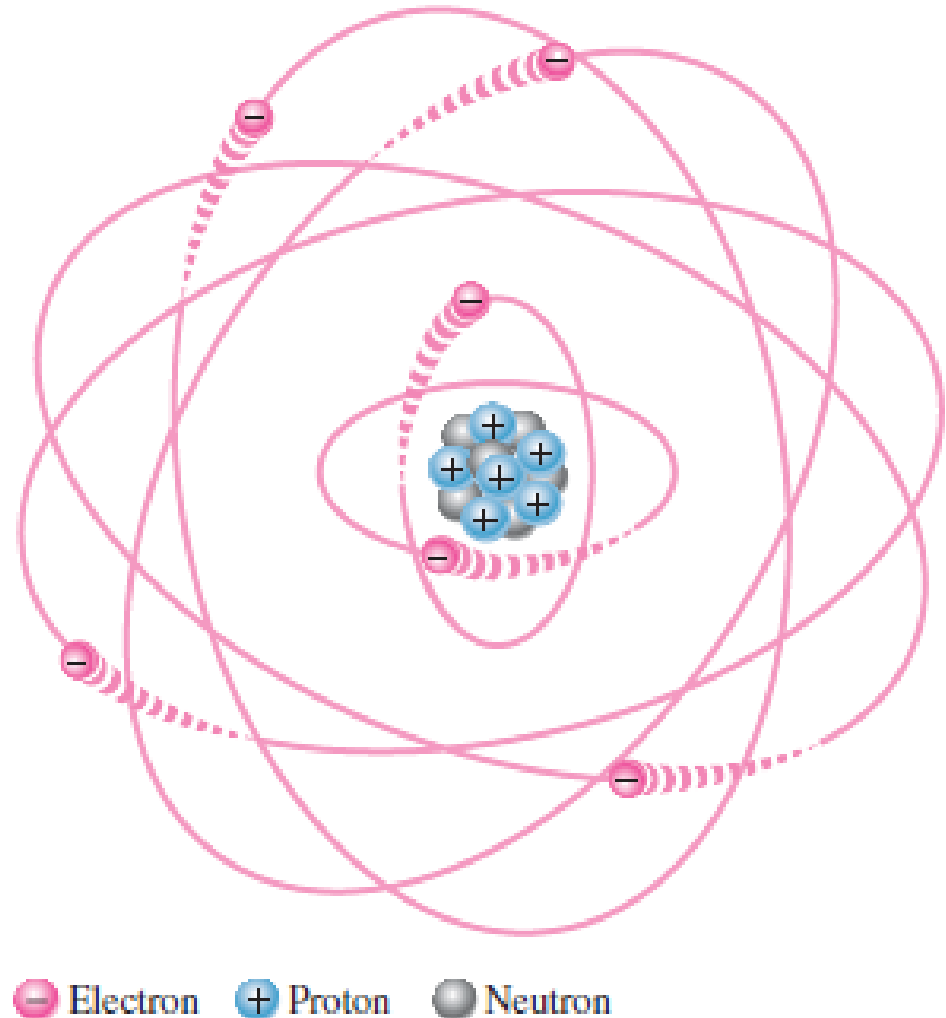
- **E.g. : A washing machine**
  - **Electrical circuit:** comprising a plug socket, fuse, on/off switch, heater and motor, which rotates the drum
  - **Electronic circuit:**
    - The desired wash cycle and temperature are inputted by the user via the control panel and are interpreted by electronic circuits.
    - When the electronic circuit has interpreted these commands, it sends signals to the electrical circuit to operate the heater and motor, to heat and rotate the drum

# Electrical Vs. Electronic Circuits

- **Control of Conductivity is the Key to Modern Electronic Devices**
  - Conductivity, is the ease with which a given material conducts electricity
    - Metals: High conductivity
    - Insulators: Low Conductivity
    - Semiconductors: Conductivity can be varied by several orders of magnitude
- **It is the ability to control conductivity that make semiconductors useful as “current/voltage control elements”.**

# Atomic Structure

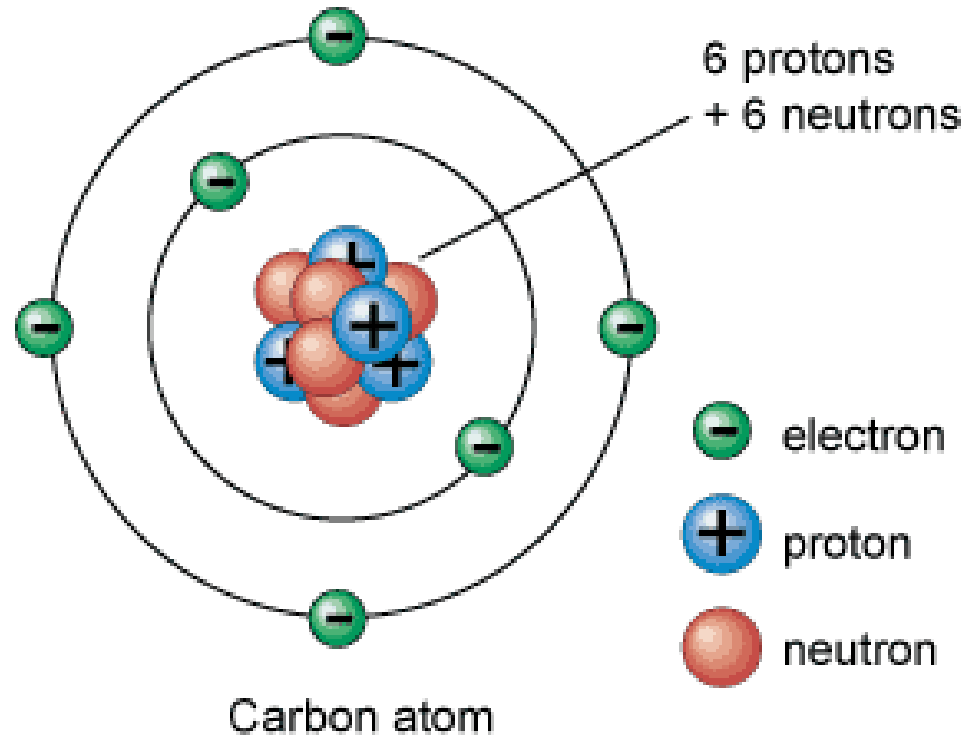
- An **atom** is the smallest particle of an element that retains the characteristics of that element
- Contains **Electrons**, **Protons** & **Neutrons**
- Electrons orbit around the **nucleus**, that consists of **neutrons** and **protons**





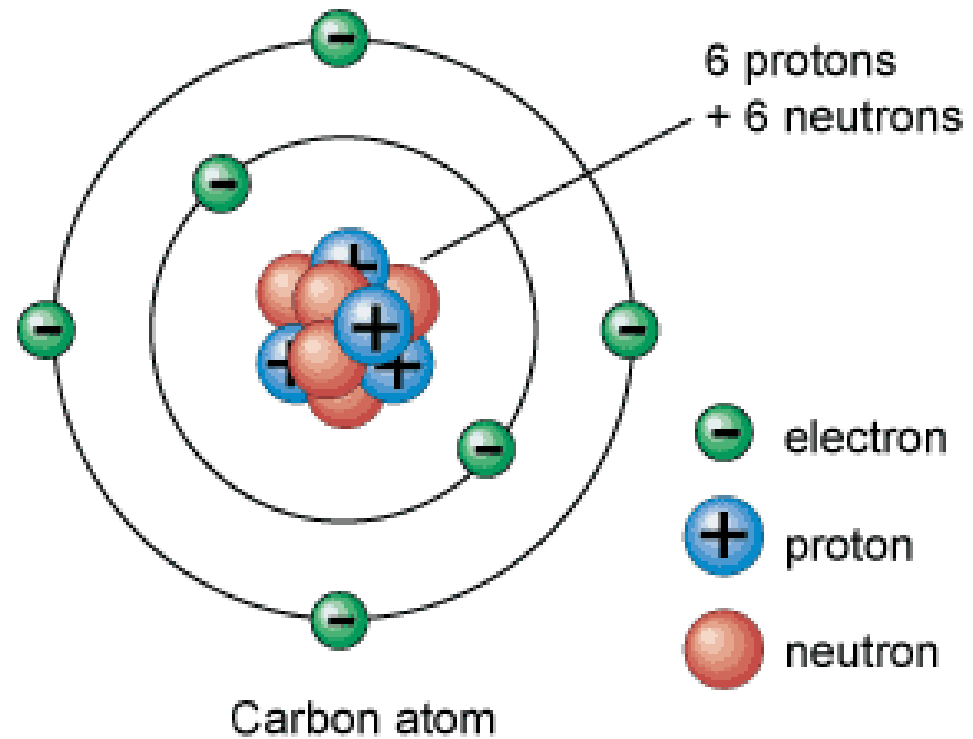
# Atomic Structure

- Electrons orbit the nucleus at a certain distance
- The electrons closer to the nucleus have less energy, than those further away
- The orbits are grouped into energy bands, called **'Shells'**



# Valence Electrons

- Electrons furthest away from the nucleus are called **valence electrons**
- The outermost shell is the **valence shell**, or **valence band**
- Valence electrons contribute to chemical reactions, bonding and electrical properties of a material
- That is, its conductivity





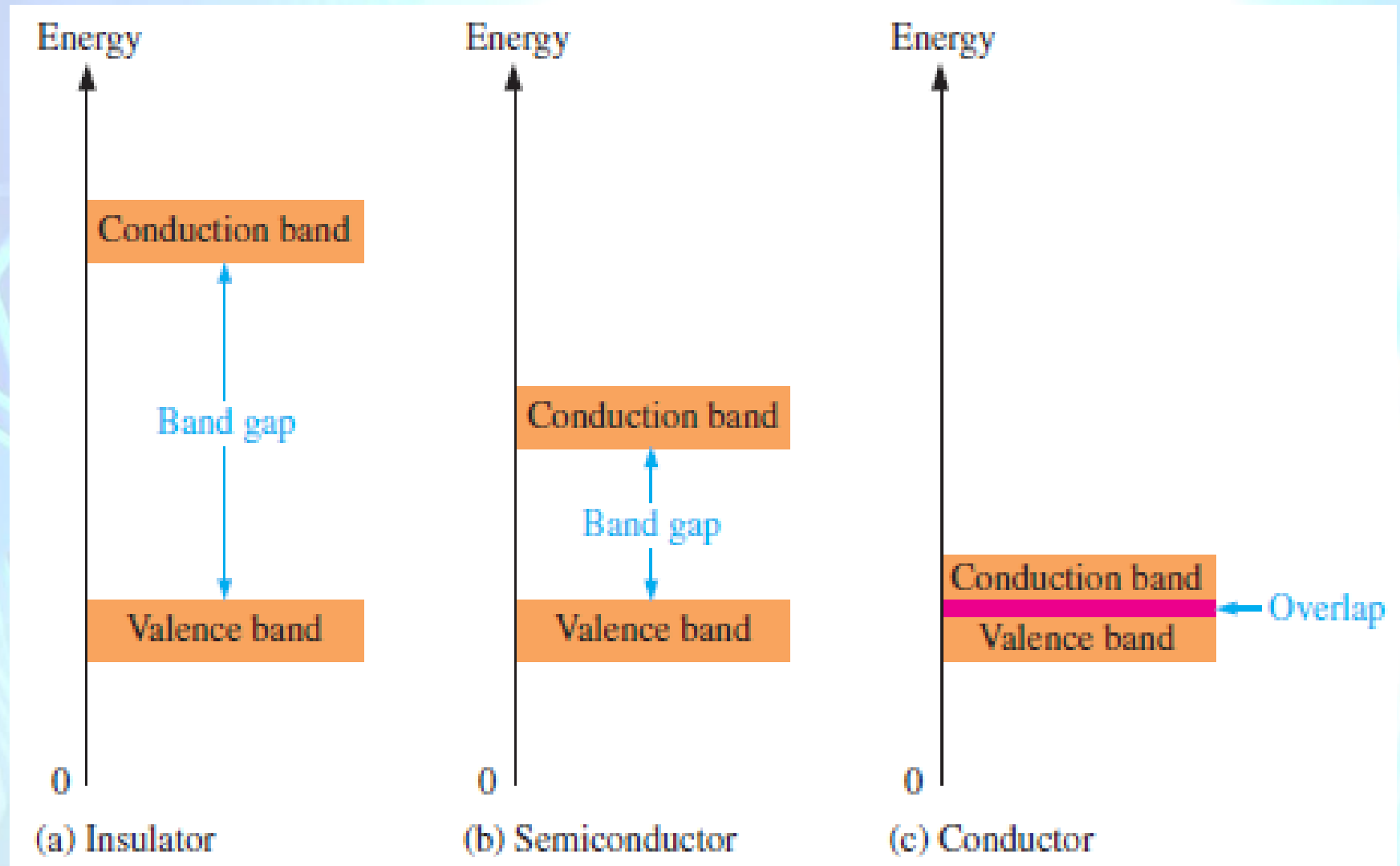
# Valance Electrons

- Electrons furthest away from the nucleus are called **valence electrons**
- If a Valence electron acquire sufficient energy it can escape from the outer shell and atom's influence → **Ionization**
- An escaped electron is a **free electron**, that **enables conductivity in materials**.

# Electrical Classification of Materials

- **Conductors:** is a material that easily conducts electrical current. Most metals are good conductors
- **Insulators:** is a material that does not conduct electrical current under normal conditions
- **Semiconductor:** is a material that is between conductors and insulators in its ability to conduct electrical current

# Energy Gap



# Semiconductors

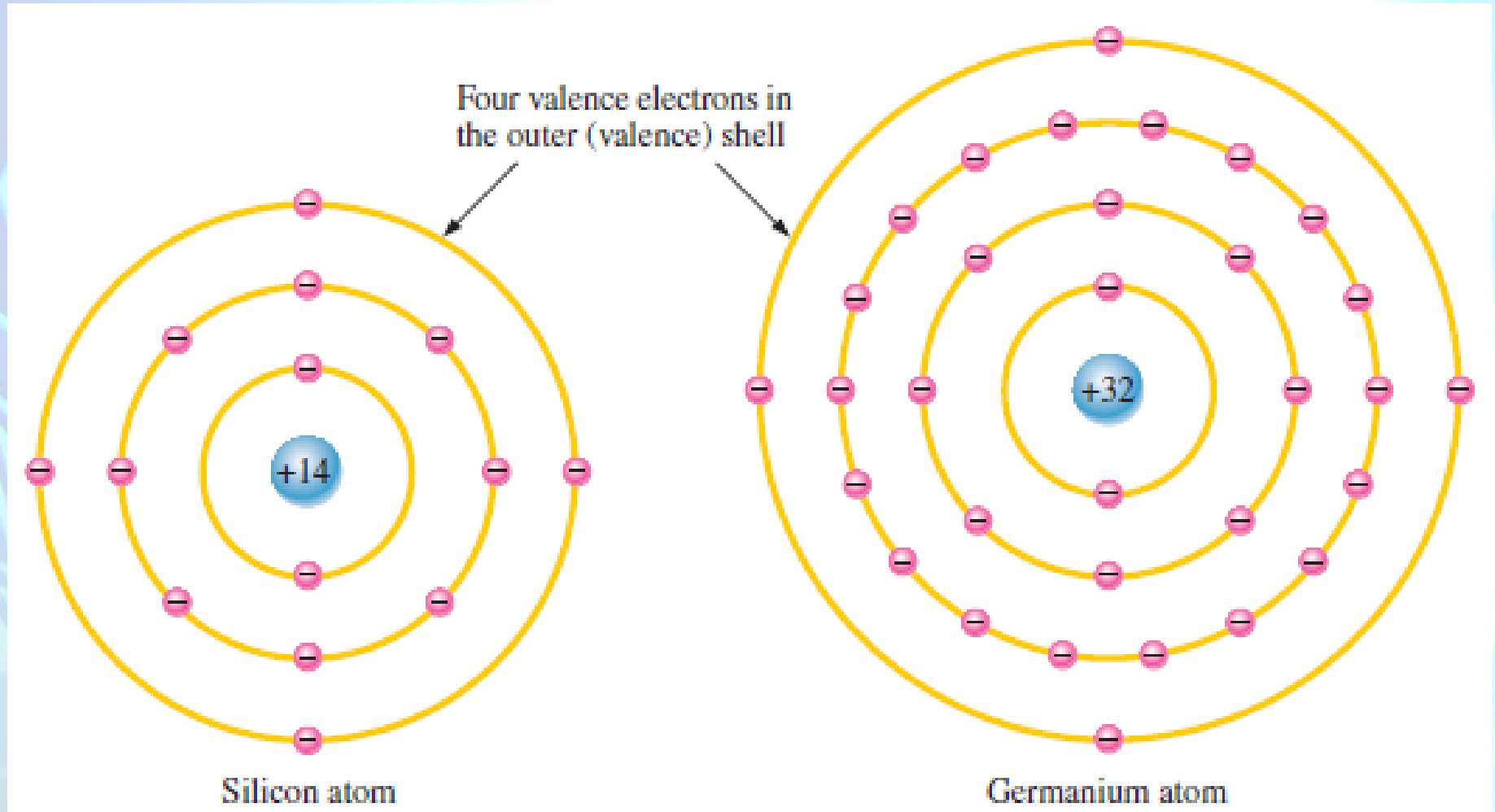
- Types of semiconductors:
  - Single-element semiconductors (intrinsic):** carbon (C), silicon (Si), germanium (Ge)
  - Compound semiconductors (extrinsic):** gallium arsenide, gallium nitride, silicon carbide

*C, Si, Ge all have 4 valence electrons*

13 IIIA	14 IVA	15 VA	16 VIA	17 VIIA	18 VIII
5 <b>B</b> Boron 10.811	6 <b>C</b> Carbon 12.0107	7 <b>N</b> Nitrogen 14.00674	8 <b>O</b> Oxygen 15.9994	9 <b>F</b> Fluorine 18.9984032	2 <b>He</b> Helium 4.002602
13 <b>Al</b> Aluminum 26.981538	14 <b>Si</b> Silicon 28.0855	15 <b>P</b> Phosphorus 30.973761	16 <b>S</b> Sulfur 32.066	17 <b>Cl</b> Chlorine 35.453	10 <b>Ne</b> Neon 20.1797
31 <b>Ga</b> Gallium 69.723	32 <b>Ge</b> Germanium 72.64	33 <b>As</b> Arsenic 74.92160	34 <b>Se</b> Selenium 78.96	35 <b>Br</b> Bromine 79.904	18 <b>Ar</b> Argon 39.948
49 <b>In</b> Indium 114.818	50 <b>Sn</b> Tin 118.710	51 <b>Sb</b> Antimony 121.760	52 <b>Te</b> Tellurium 127.60	53 <b>I</b> Iodine 126.90447	36 <b>Kr</b> Krypton 83.798
					54 <b>Xe</b> Xenon 131.293

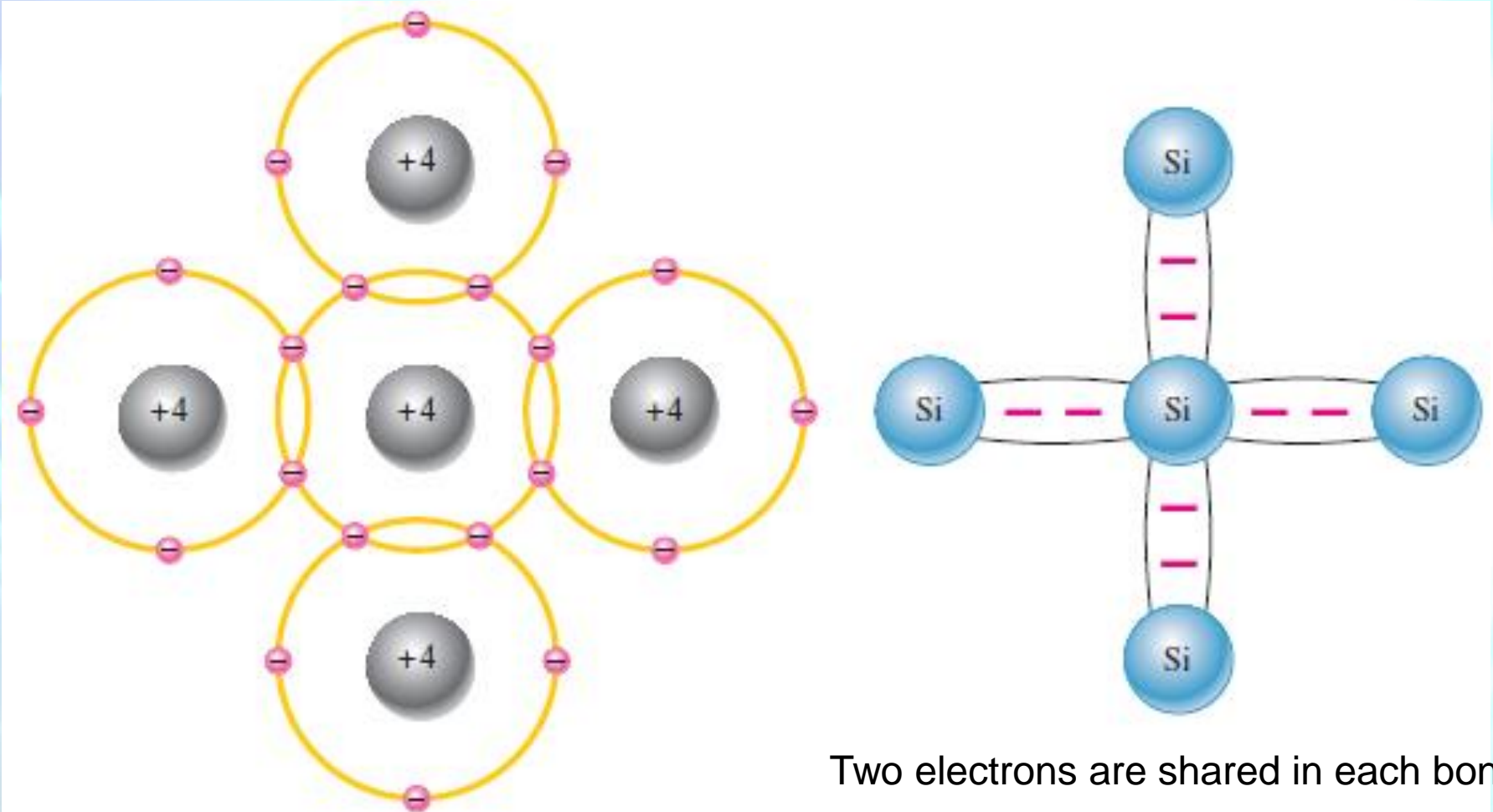
# Atomic Structure of Si & Ge

- 4 valance electrons in the outer shell



# Covalent Bond

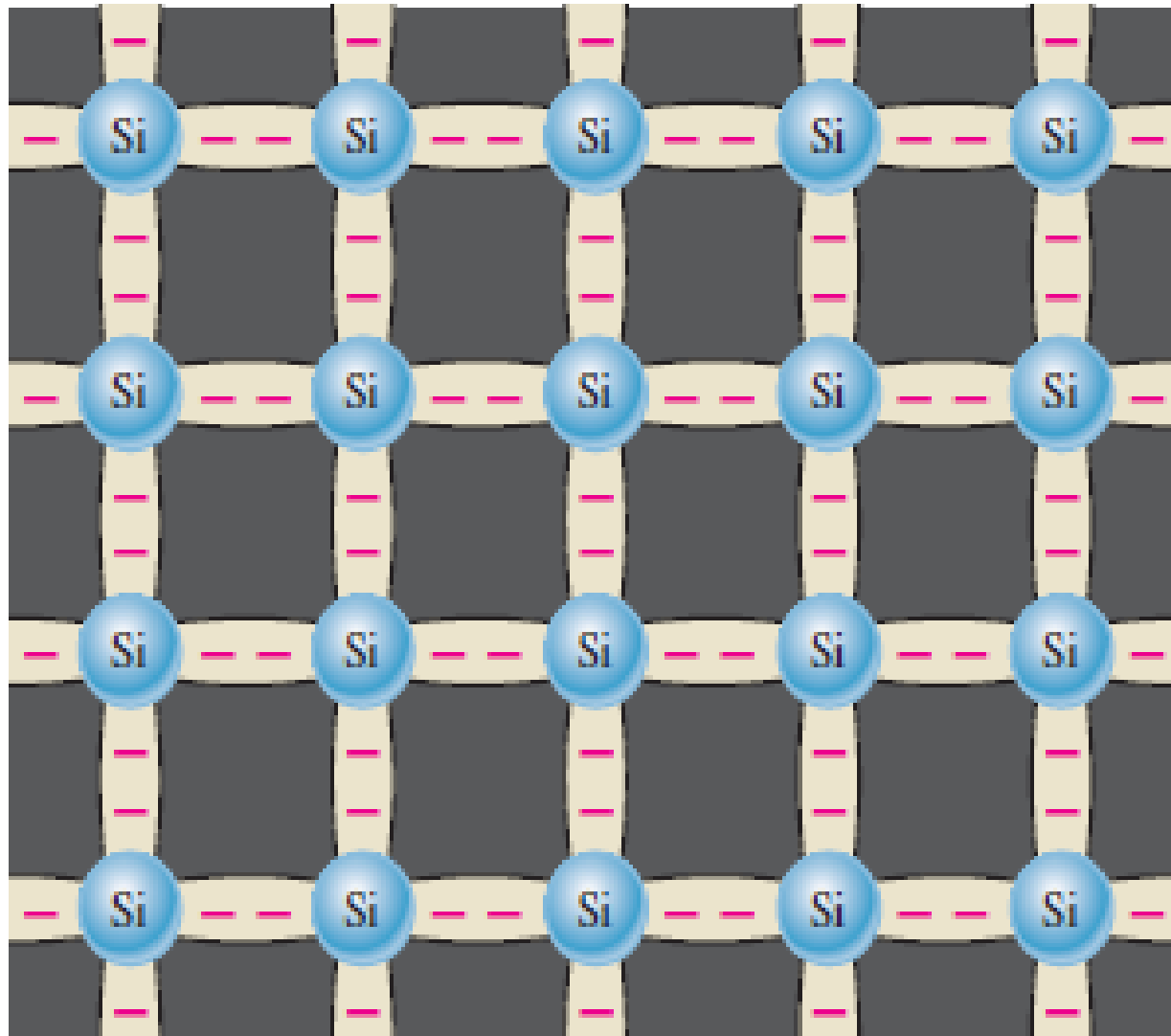
- When atoms combine to form solids they arrange them in a crystal structure held together by **covalent bonds**



Two electrons are shared in each bond

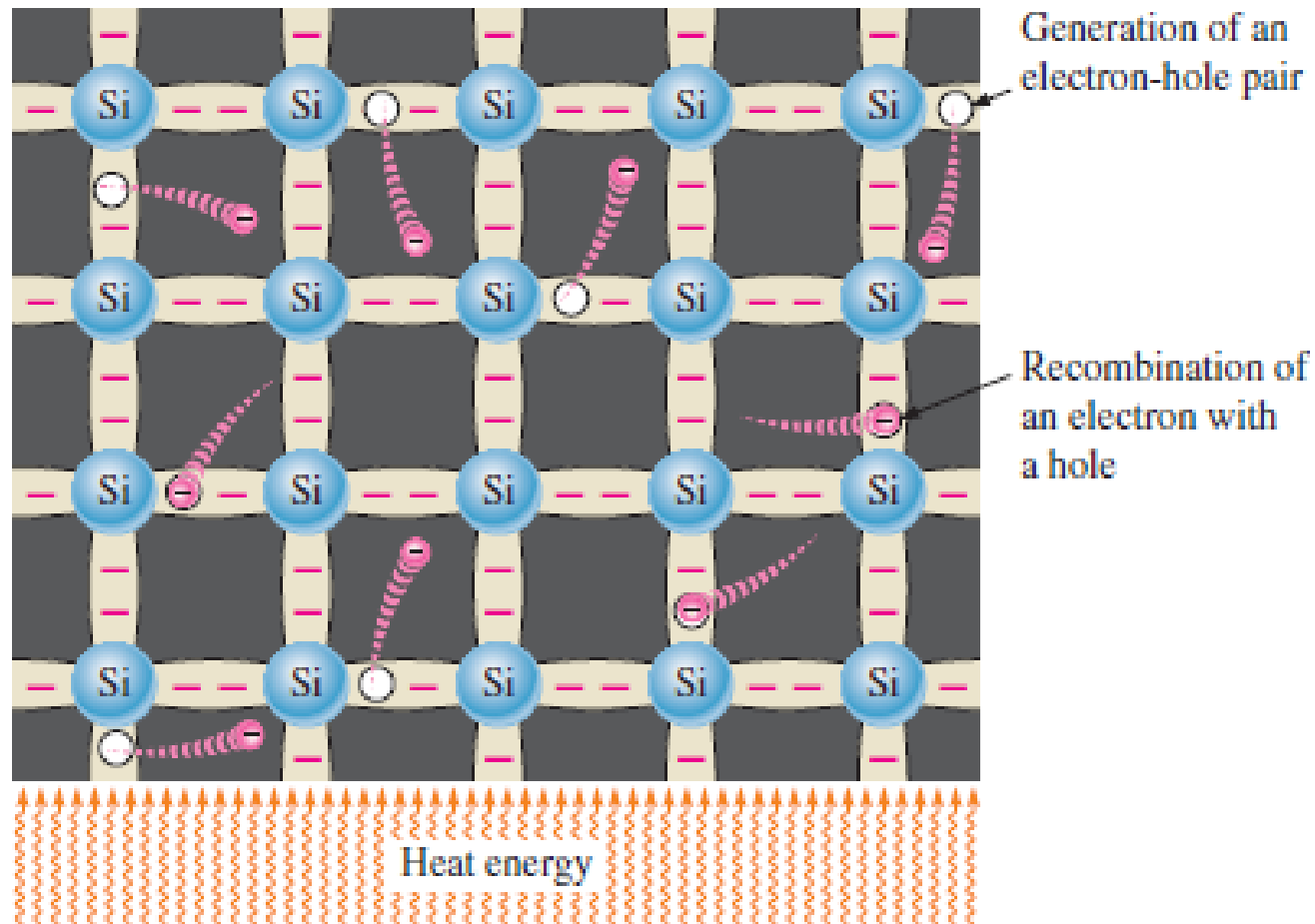


# Intrinsic Si Crystal



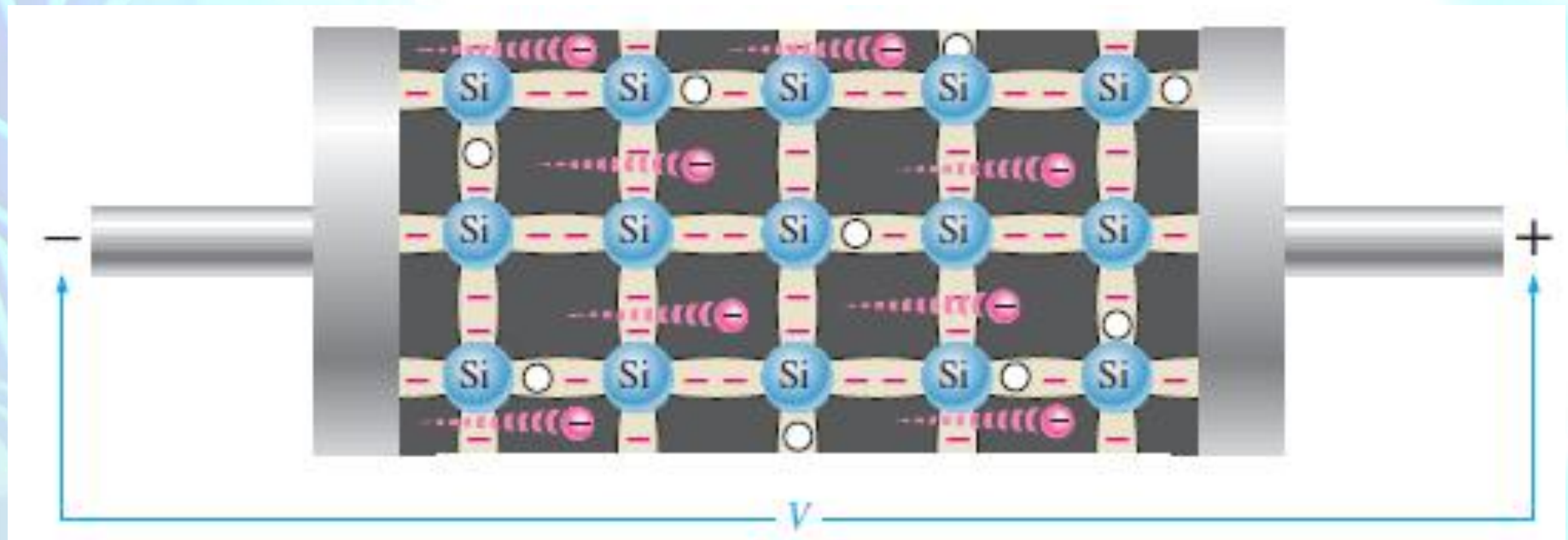
# Intrinsic Si Crystal

- An intrinsic (pure) silicon crystal at room temperature has sufficient heat (thermal) energy for some valence electrons to jump the gap from the valence band into the conduction band to create **conduction electrons**



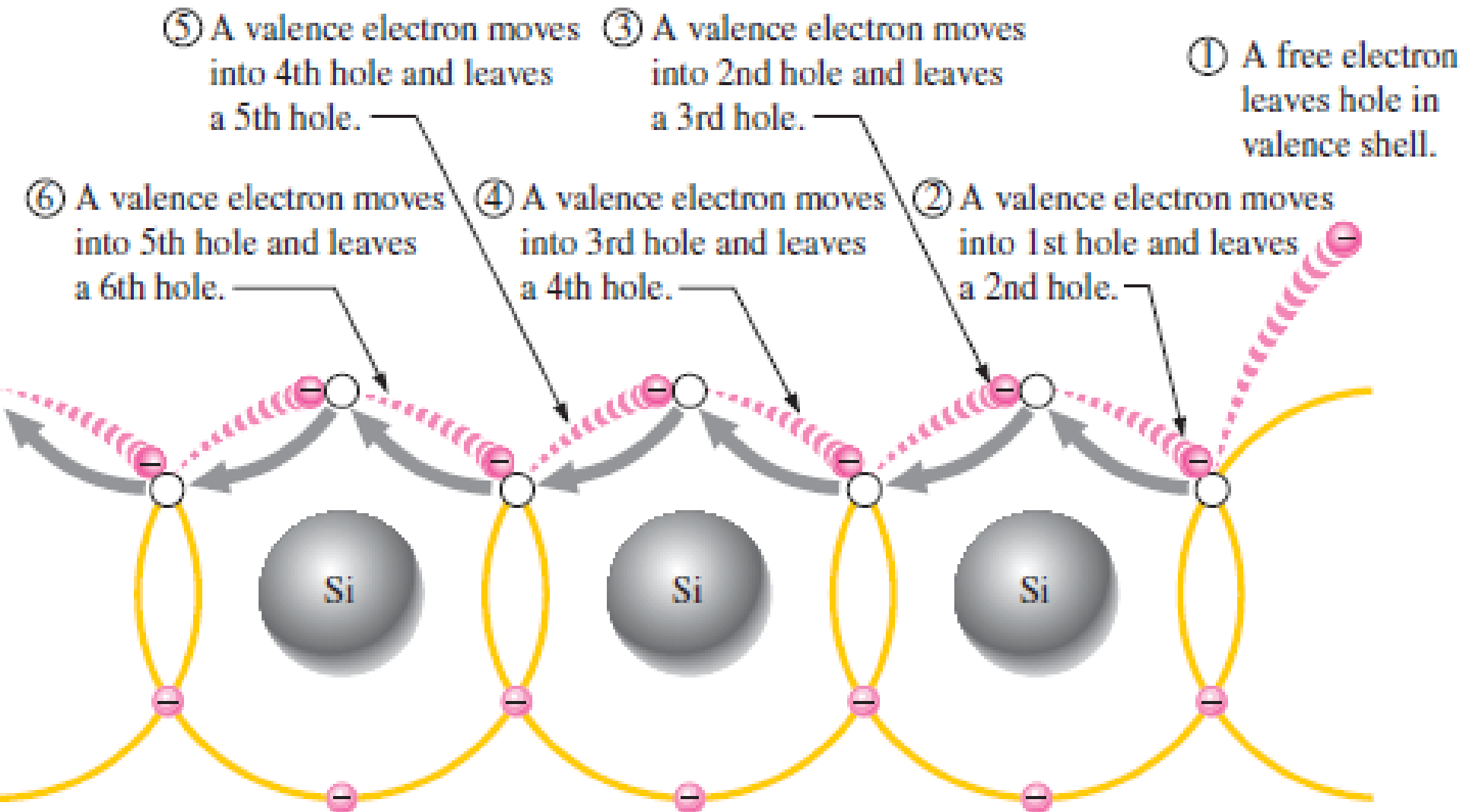
# Electron and Hole Current

- In the presence of an electric field...
- Electron Current



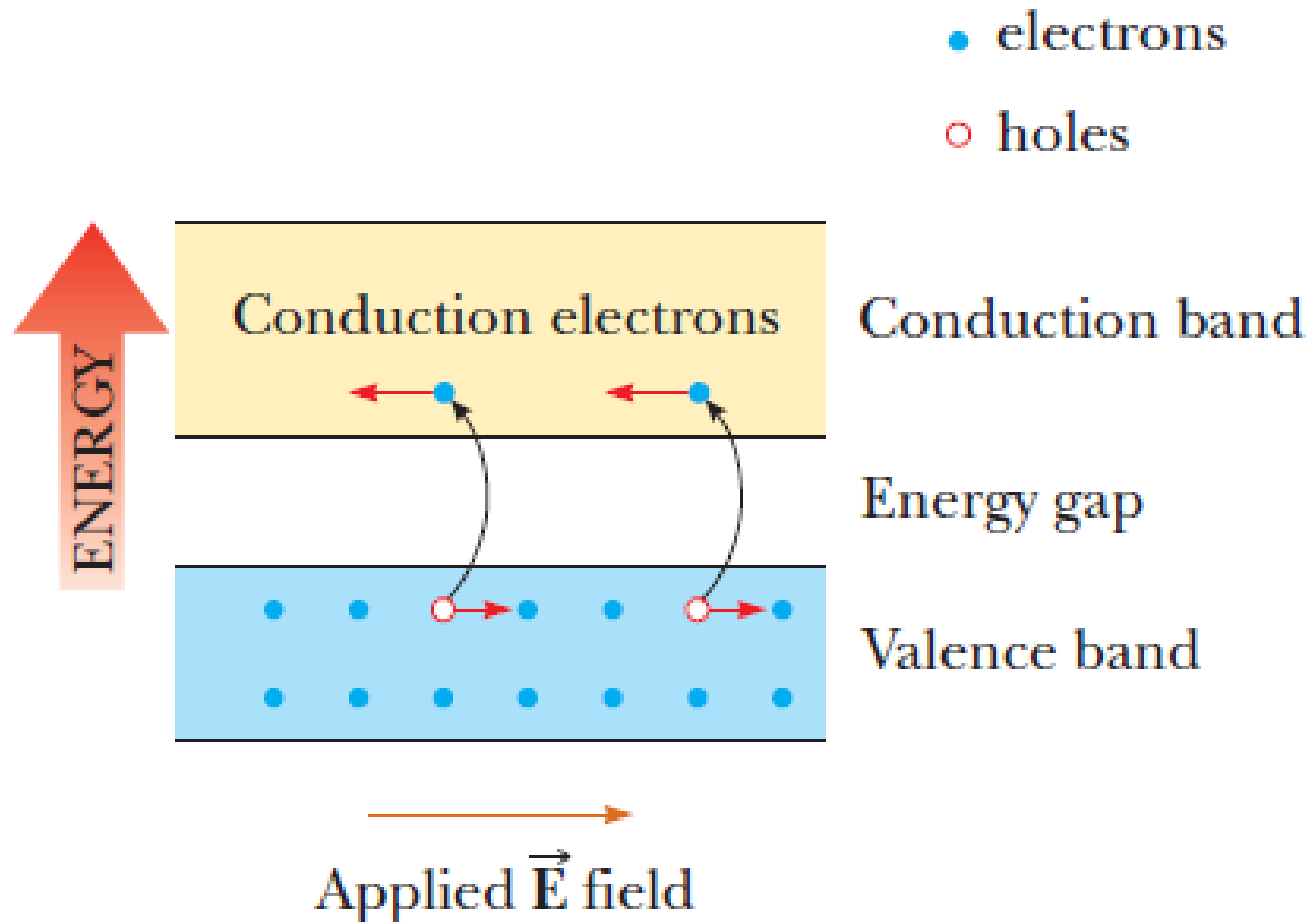
# Electron and Hole Current

- Hole Current



# Electron and Hole Current

- In the presence of an electric field: **Electron & Hole Current**



# Extrinsic Semiconductors

- Because of the limited number of free electrons in the conduction band and holes in the valence band intrinsic materials do not conduct current well
- Thus intrinsic silicon (or germanium) must be modified by increasing the number of free electrons or holes to increase its conductivity and make it useful in electronic devices
- This is done by adding impurities to the intrinsic material (known as **Doping**)



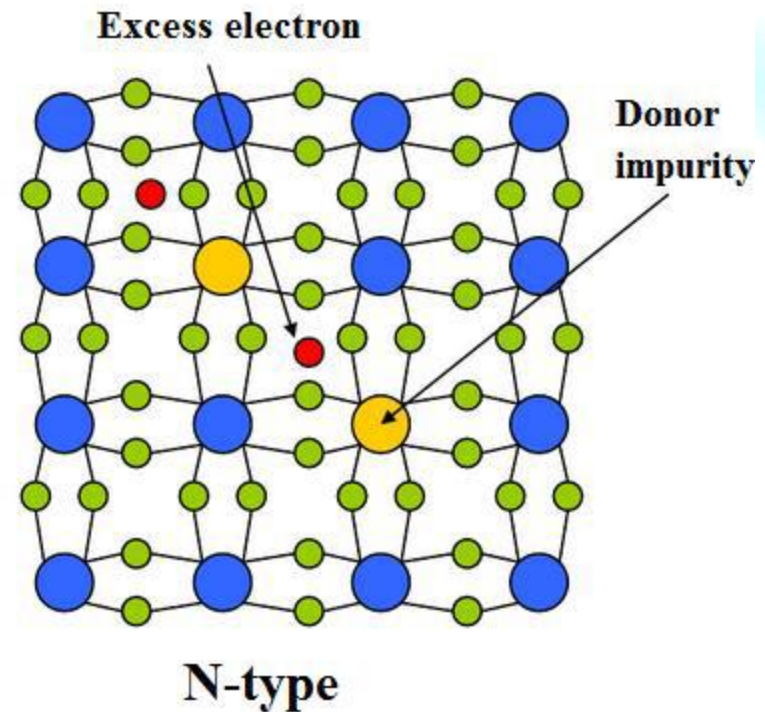
# N-type Semiconductors

- To increase the number of electrons in the conduction-band **Group-V** elements are added

13	IIIA	14	IVA	15	VA	16	VIA
5	10.811	6	12.011	7	14.007	8	15.999
<b>B</b>		<b>C</b>		<b>N</b>		<b>O</b>	
BORON		CARBON		NITROGEN		OXYGEN	
13	26.982	14	28.086	15	30.974	16	32.065
<b>Al</b>		<b>Si</b>		<b>P</b>		<b>S</b>	
ALUMINIUM		SILICON		PHOSPHORUS		SULPHUR	
31	69.723	32	72.64	33	74.922	34	78.96
<b>Ga</b>		<b>Ge</b>		<b>As</b>		<b>Se</b>	
GALLIUM		GERMANIUM		ARSENIC		SELENIUM	
49	114.82	50	118.71	51	121.76	52	127.60
<b>In</b>		<b>Sn</b>		<b>Sb</b>		<b>Te</b>	
INDIUM		TIN		ANTIMONY		TELLURIUM	
81	204.38	82	207.2	83	208.98	84	(209)
<b>Tl</b>		<b>Pb</b>		<b>Bi</b>		<b>Po</b>	
THALLIUM		LEAD		BISMUTH		POLONIUM	

## Donor dopants

Phosphorus, Arsenic, Antimony;  
(Group 5 atoms)



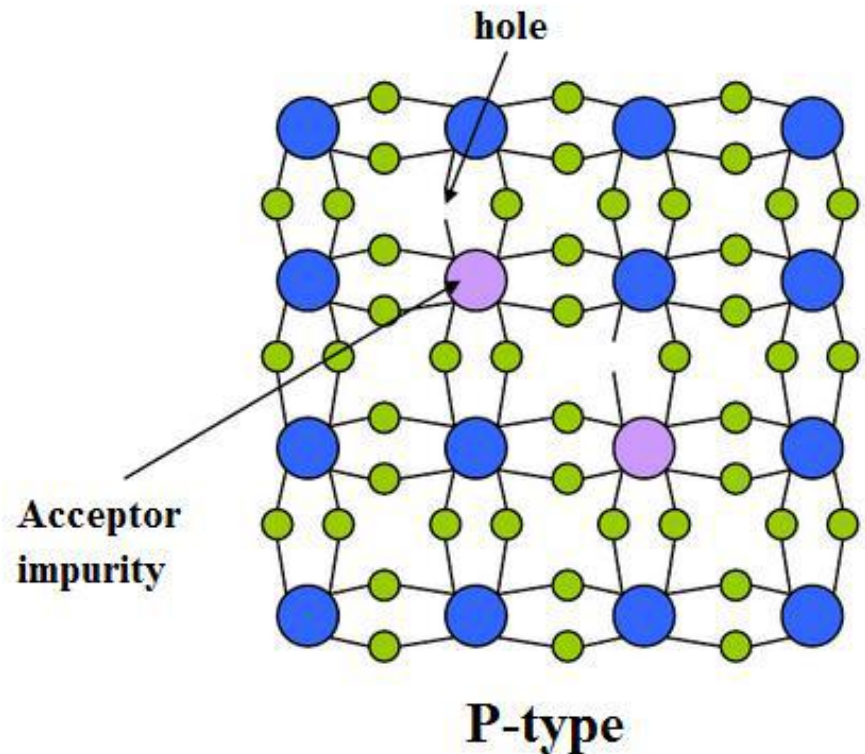
# P-type Semiconductors

- To increase the number of holes **Group-III** elements are added

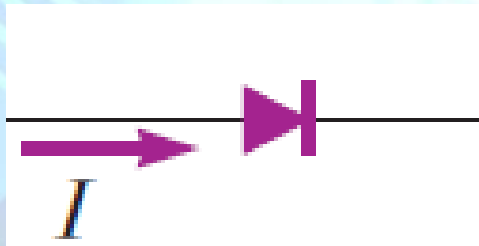
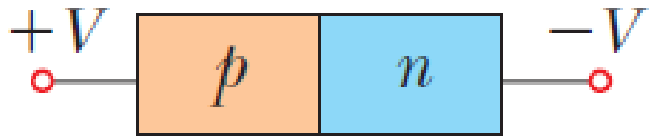
13	IIIA	14	IVA	15	VA	16	VIA
5	10.811	6	12.011	7	14.007	8	15.999
<b>B</b>	<b>C</b>	<b>N</b>	<b>O</b>				
BORON	CARBON	NITROGEN	OXYGEN				
13	26.982	14	28.086	15	30.974	16	32.065
<b>Al</b>	<b>Si</b>	<b>P</b>	<b>S</b>				
ALUMINIUM	SILICON	PHOSPHORUS	SULPHUR				
31	69.723	32	72.64	33	74.922	34	78.96
<b>Ga</b>	<b>Ge</b>	<b>As</b>	<b>Se</b>				
GALLIUM	GERMANIUM	ARSENIC	SELENIUM				
49	114.82	50	118.71	51	121.76	52	127.60
<b>In</b>	<b>Sn</b>	<b>Sb</b>	<b>Te</b>				
INDIUM	TIN	ANTIMONY	TELLURIUM				
81	204.38	82	207.2	83	208.98	84	(209)
<b>Tl</b>	<b>Pb</b>	<b>Bi</b>	<b>Po</b>				
THALLIUM	LEAD	BISMUTH	POLONIUM				

## Acceptor dopants

Boron, Aluminum, Gallium, Indium;  
(Group 3 atoms)



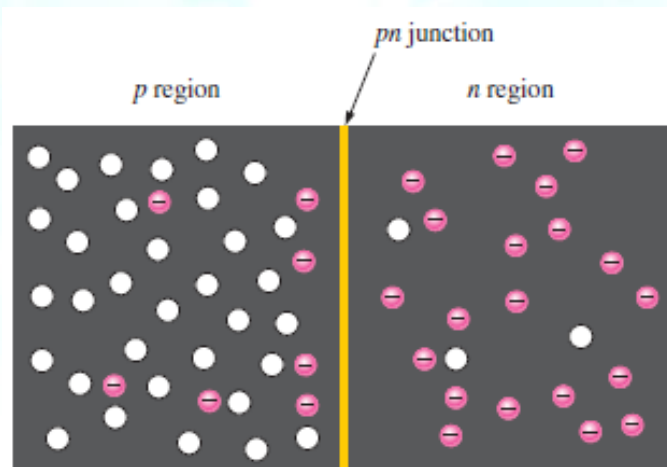
# The PN-Junction (Diode)



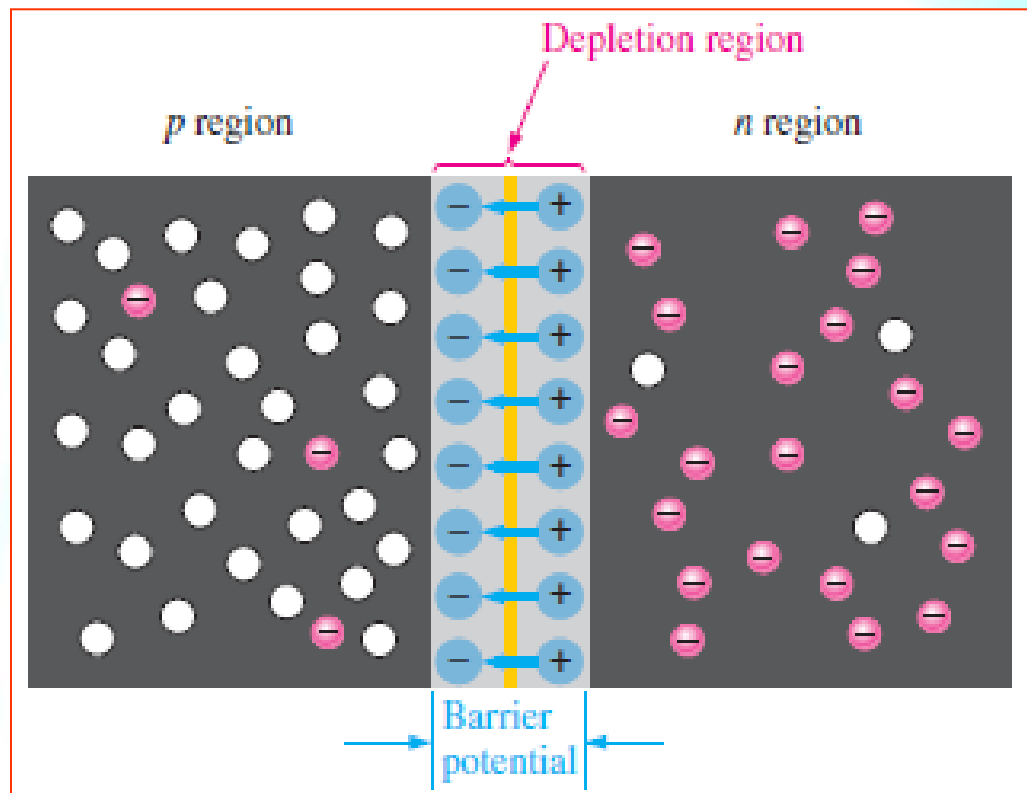
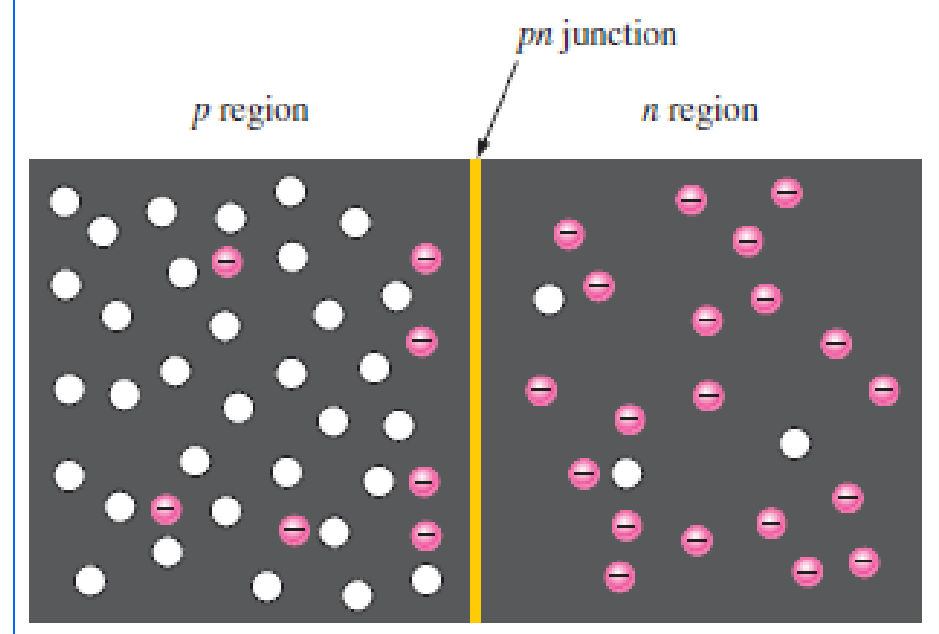


# The PN-Junction (Diode)

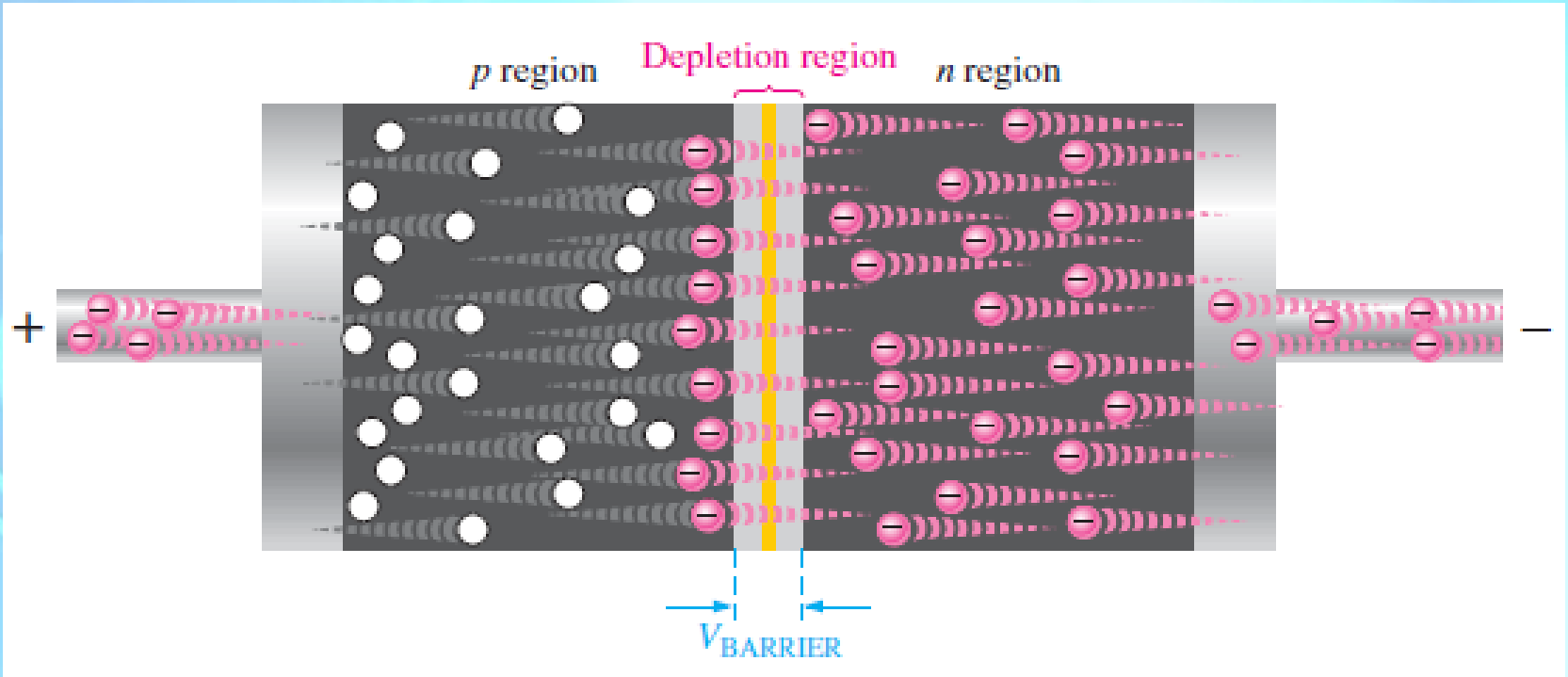
- The net charge in the **n** or **p** type semiconductor is zero
  - The no. of electrons and protons are equal throughout the material
- When a pn-junction is formed
  - n-region has more electrons and p-region has more holes
  - Free electrons near the junction in n-region diffuse across to p-region to combine with the holes near the junction
  - Near the junction, this creates a layer of +ve charges in n-region and a layer of –ve charges in p-region (known as **depletion region**)



- Equilibrium of the Depletion region is achieved when the total negative charge in the depletion region repels any further diffusion of electrons



# Forward Bias

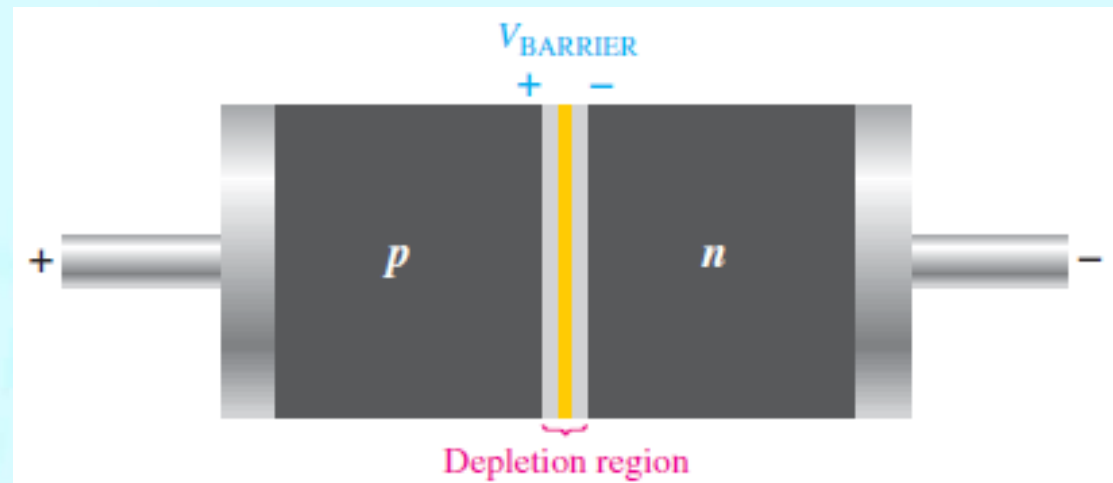
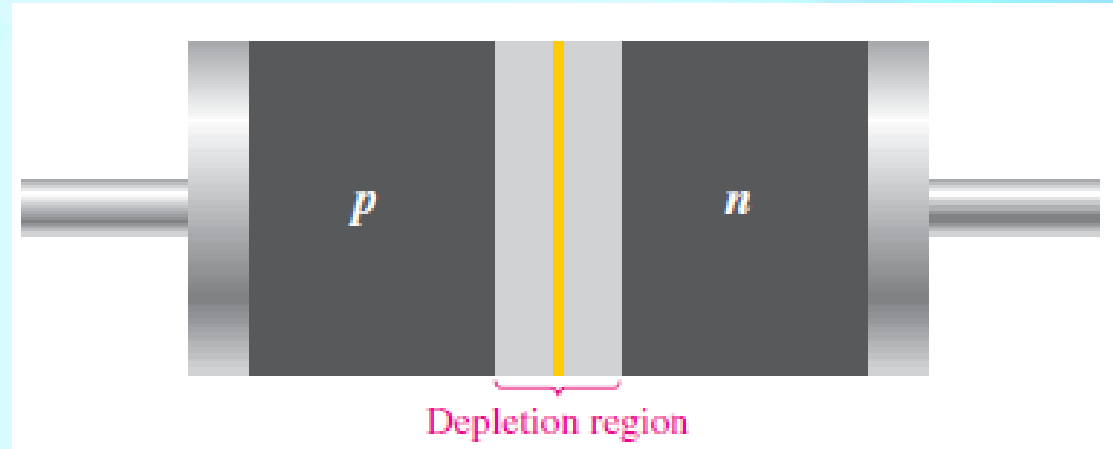


- The bias voltage provides sufficient energy to free electrons to overcome the barrier potential
- A current flows through the diode created by the **majority carriers**

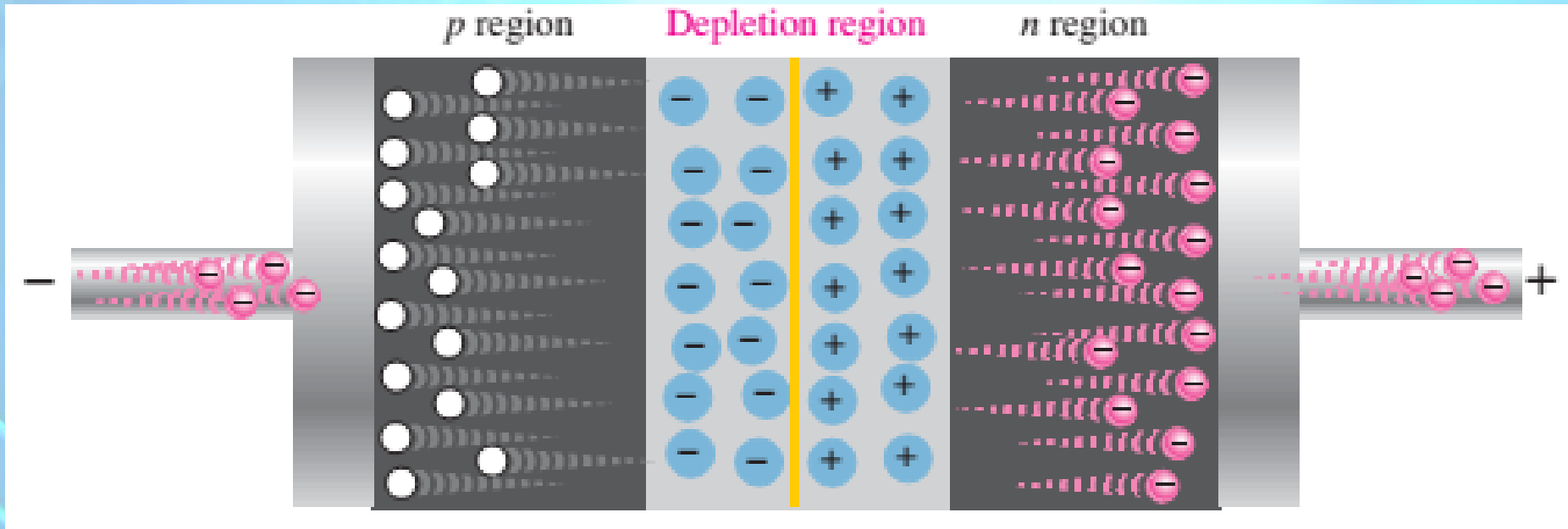


# Forward Bias

- At equilibrium (no bias)
- Forward bias narrows the depletion region and produces a voltage drop across the junction equal to the barrier potential

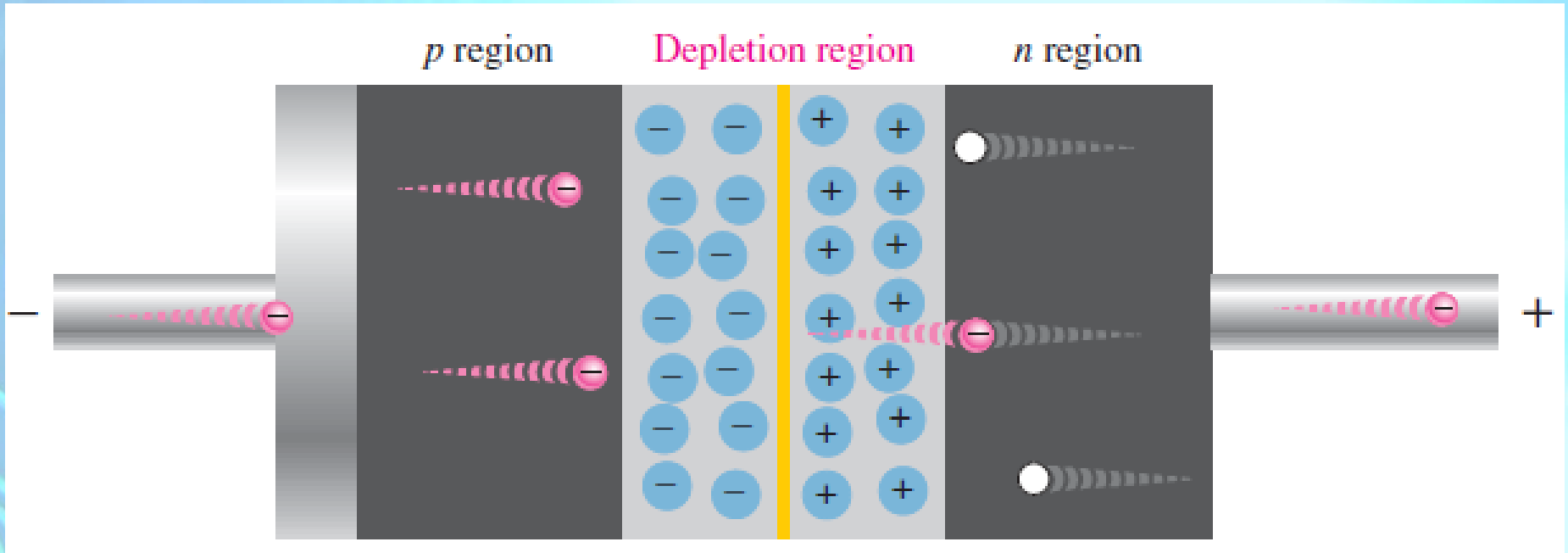


# Reverse Bias



- The diode during the short transition time immediately after reverse-bias voltage is applied
- Depletion region increases and the barrier voltage reaches the bias voltage

# Reverse Bias



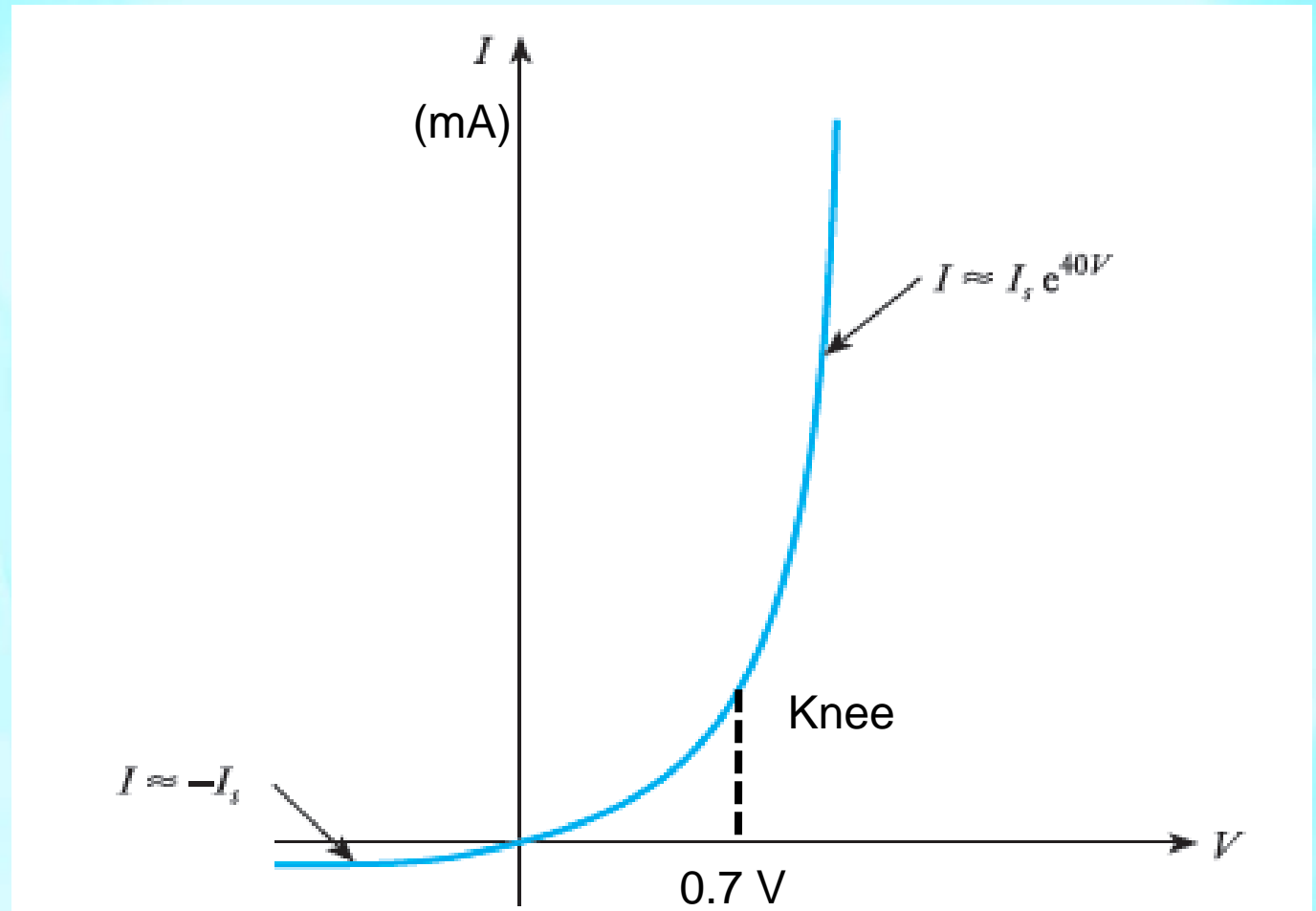
- Depletion region increases and the barrier voltage reaches the bias voltage
- A extremely small current through the diode is created by the **minority carries**

# Reverse Bias

- Reverse breakdown
  - Normally, the reverse current is so small that it can be neglected
  - However, if the external reverse-bias voltage is increased to a value called the **breakdown voltage**, the reverse current will drastically increase

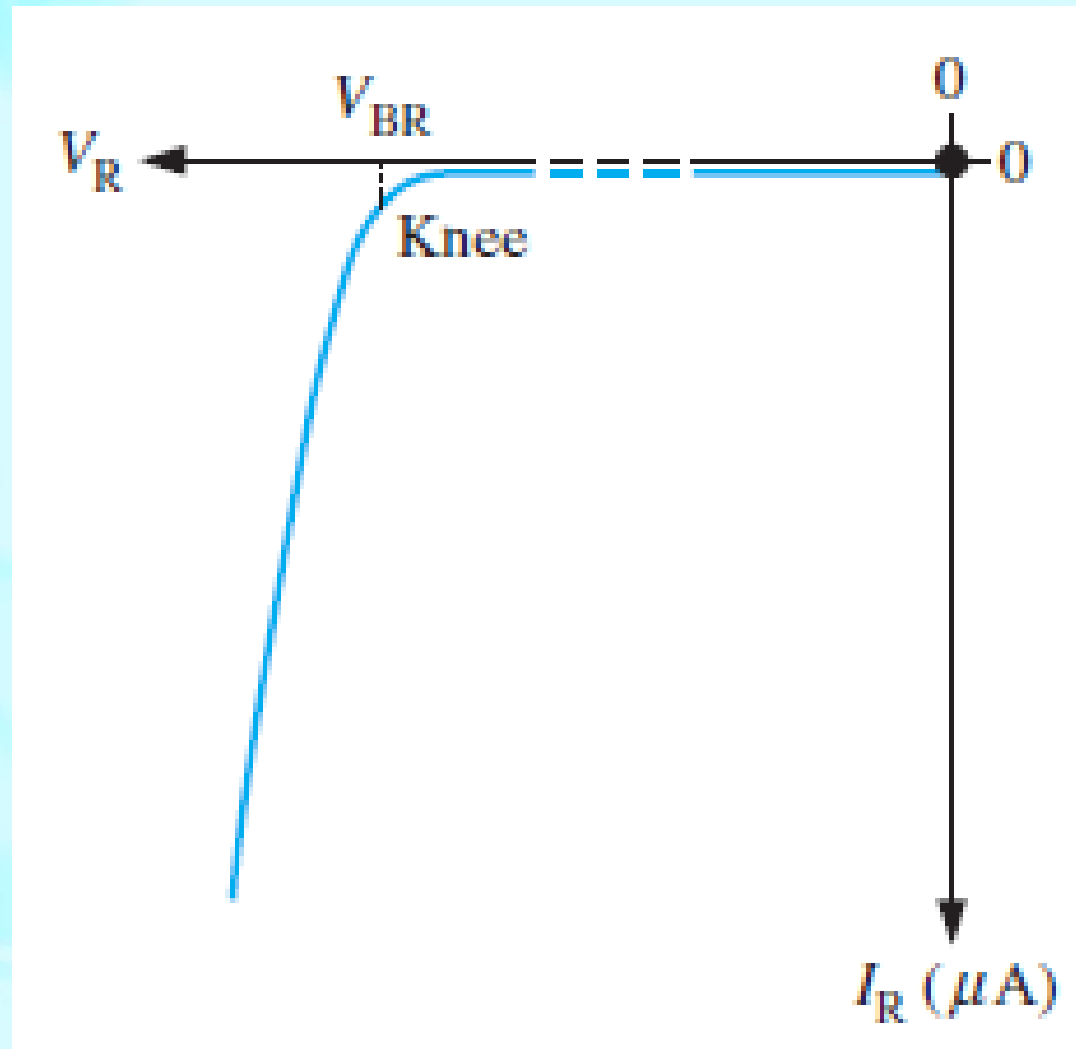
# Diode V-I Characteristics

- Forward bias



# Diode V-I Characteristics

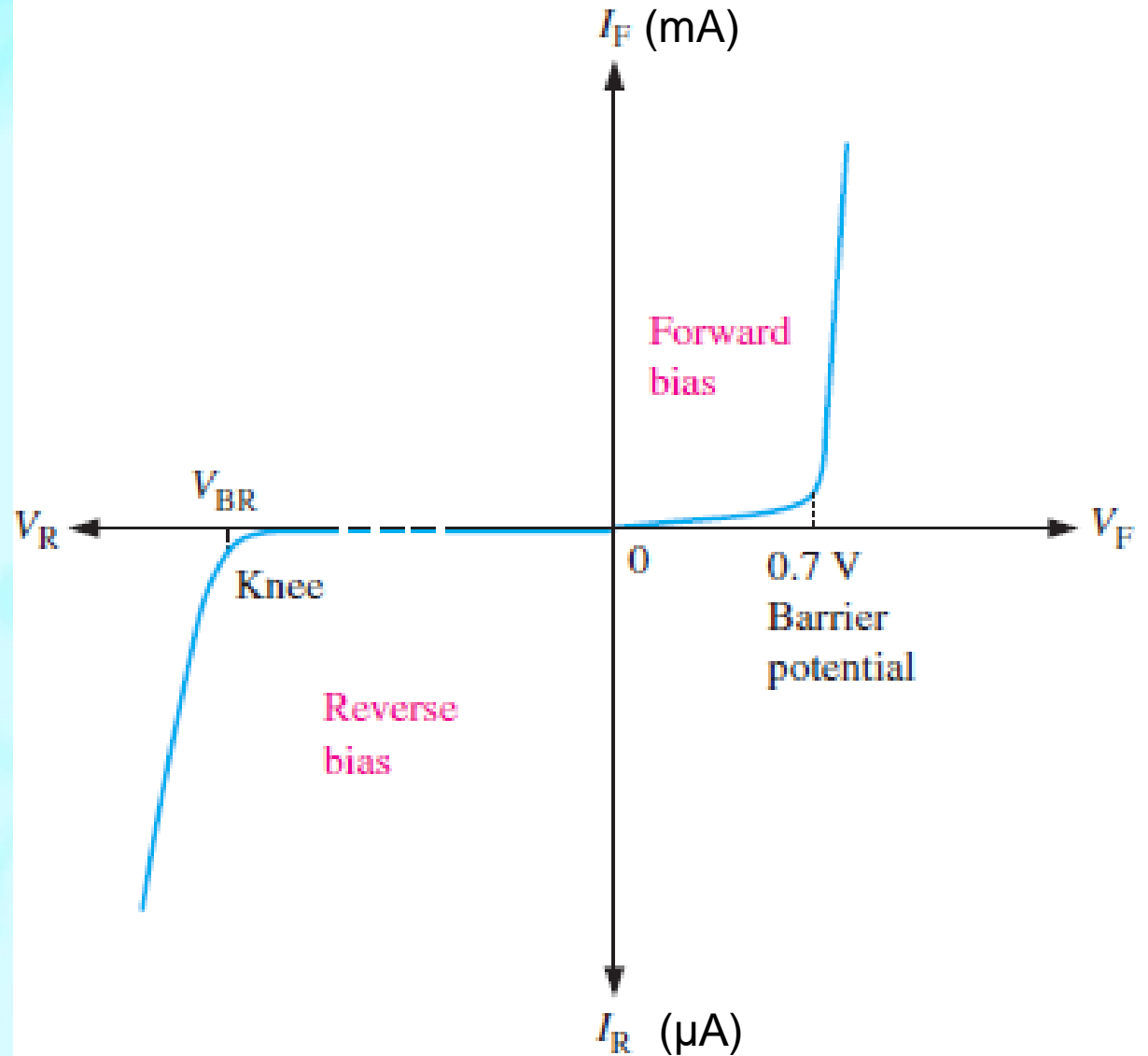
- Reverse bias





# Diode V-I Characteristics

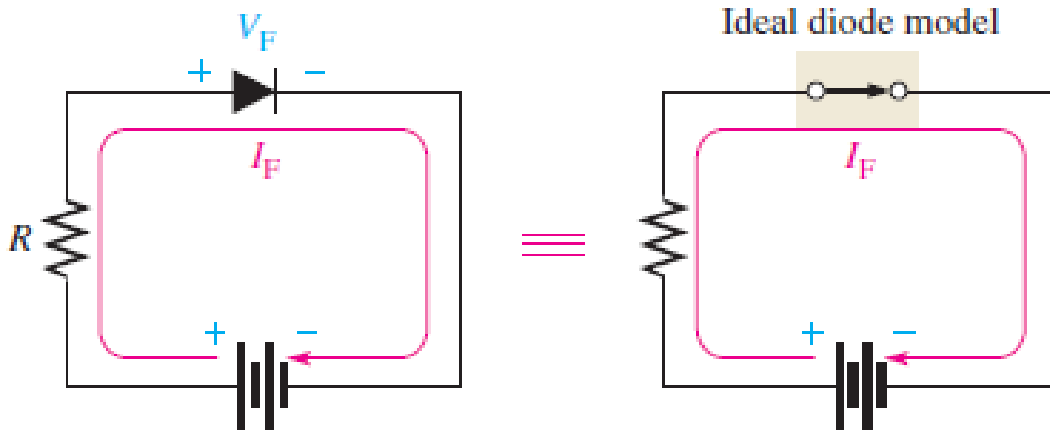
- Complete V-I curve



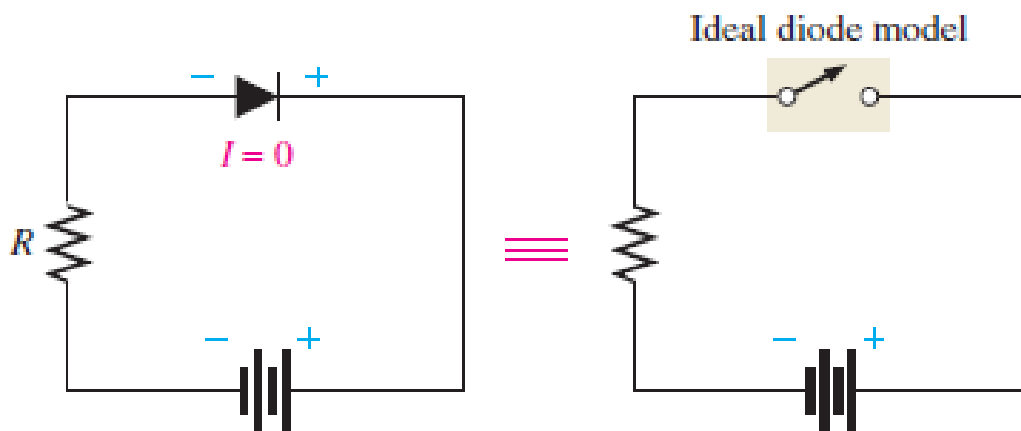
# Diode Models

- **Ideal model**
  - No barrier potential
  - No forward dynamic resistance
- Functions as a “switch”

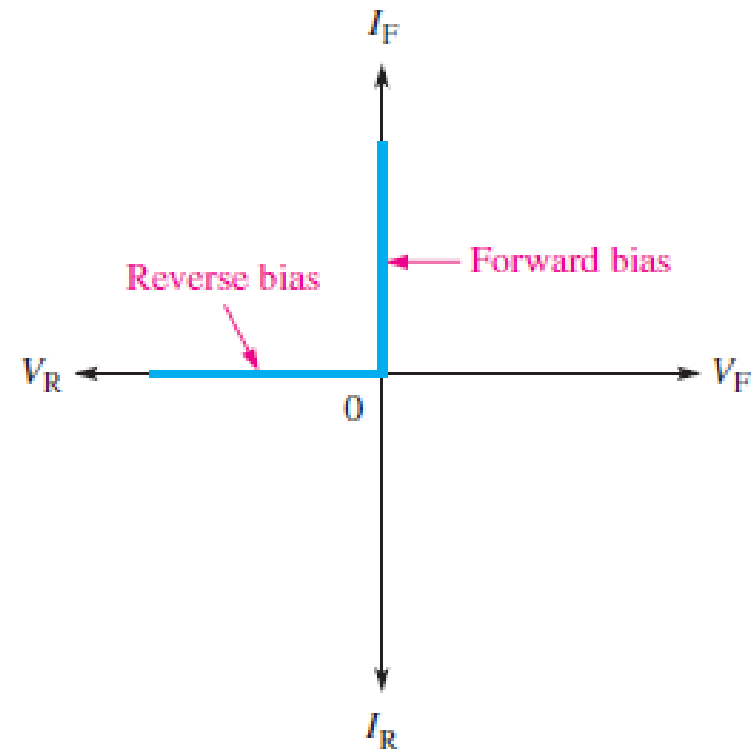
# Diode Models



(a) Forward bias



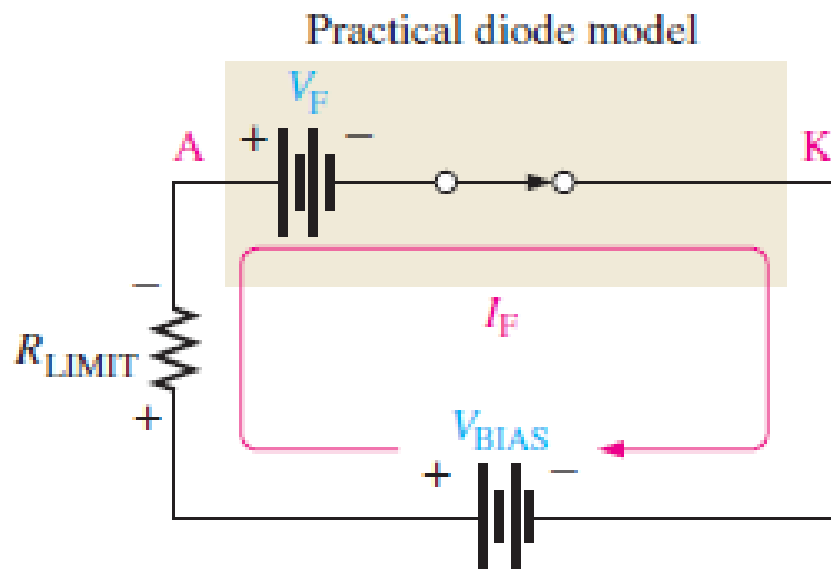
(b) Reverse bias



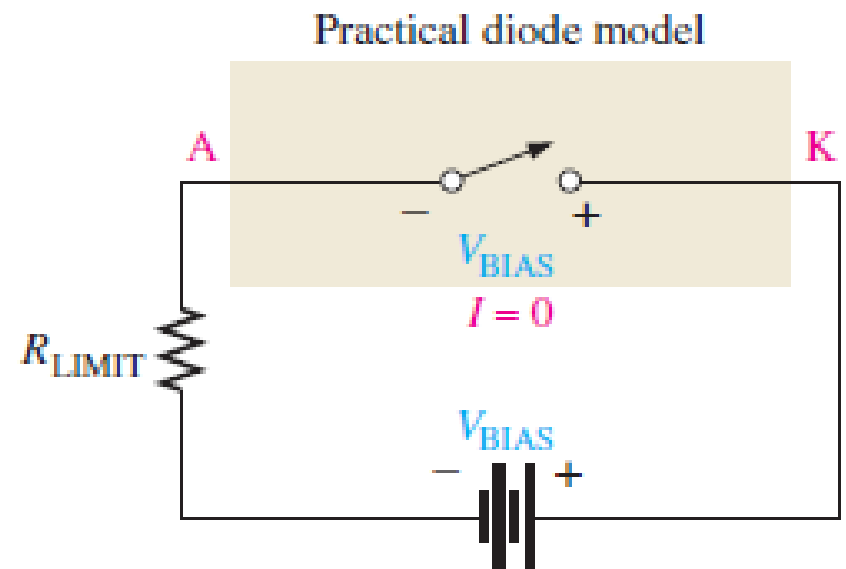
(c) Ideal  $V$ - $I$  characteristic curve (blue)

# Diode Models

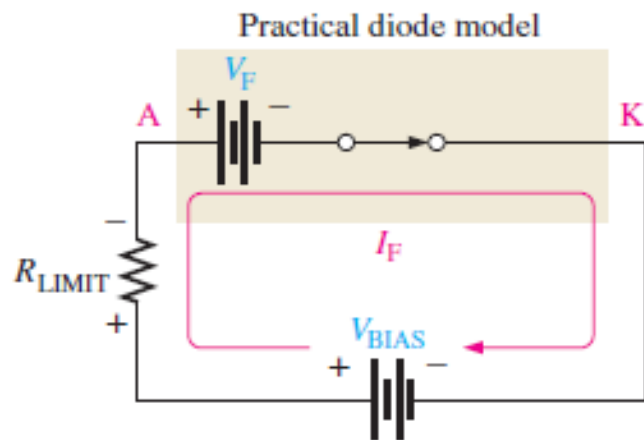
- **Practical model**
  - With barrier potential
  - No forward dynamic resistance



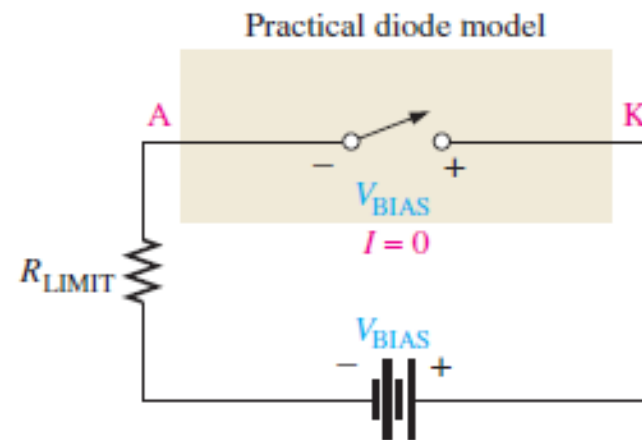
(a) Forward bias



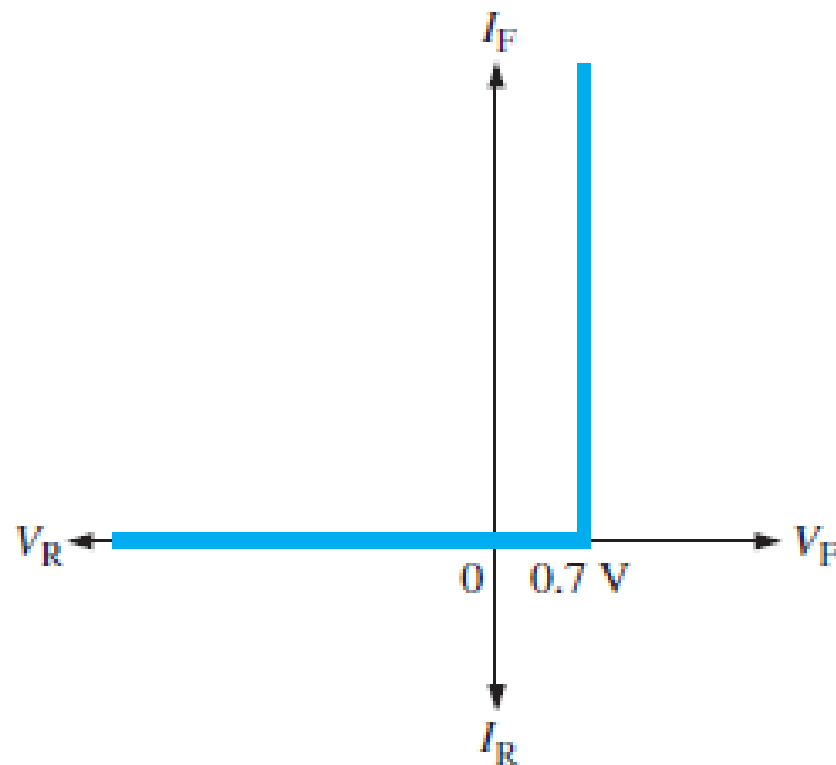
(b) Reverse bias



(a) Forward bias

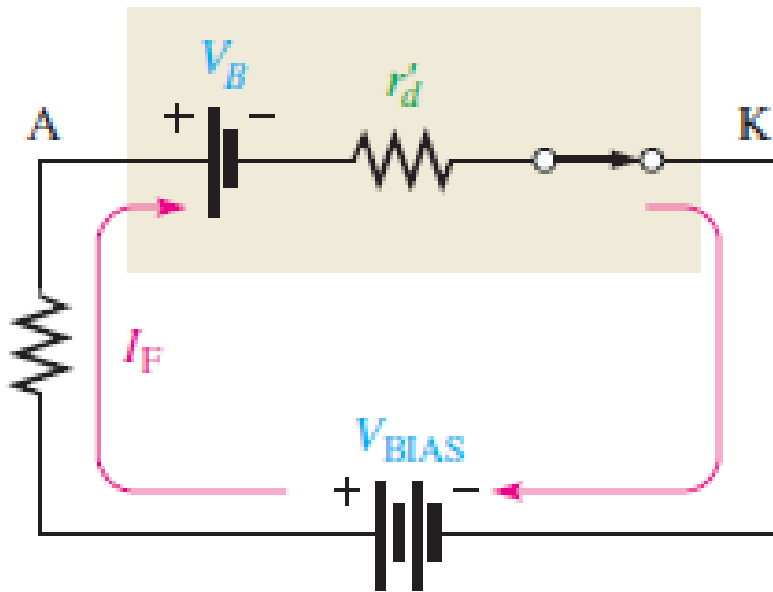


(b) Reverse bias

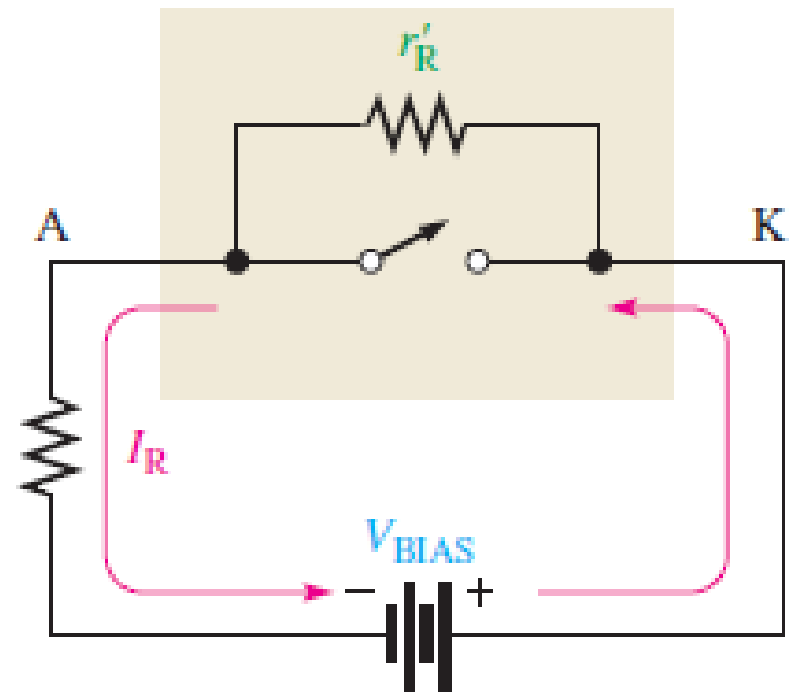


# Diode Models

- **Complete model**
  - With barrier potential
  - With forward dynamic resistance

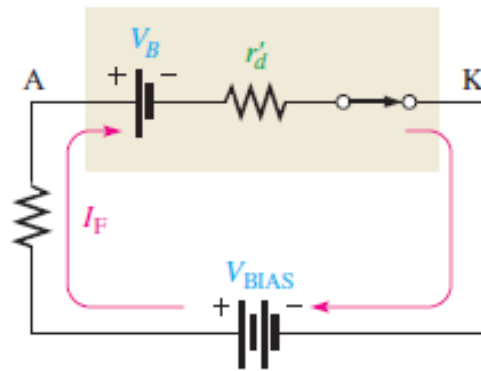


(a) Forward bias

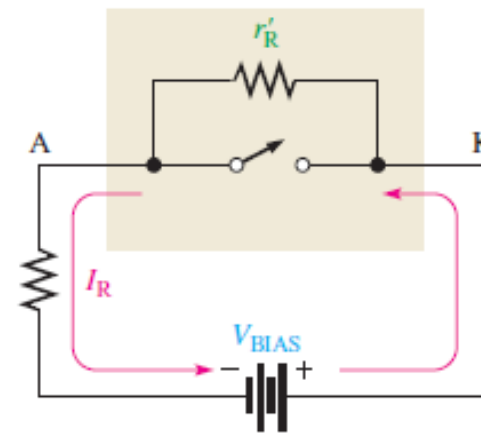


(b) Reverse bias

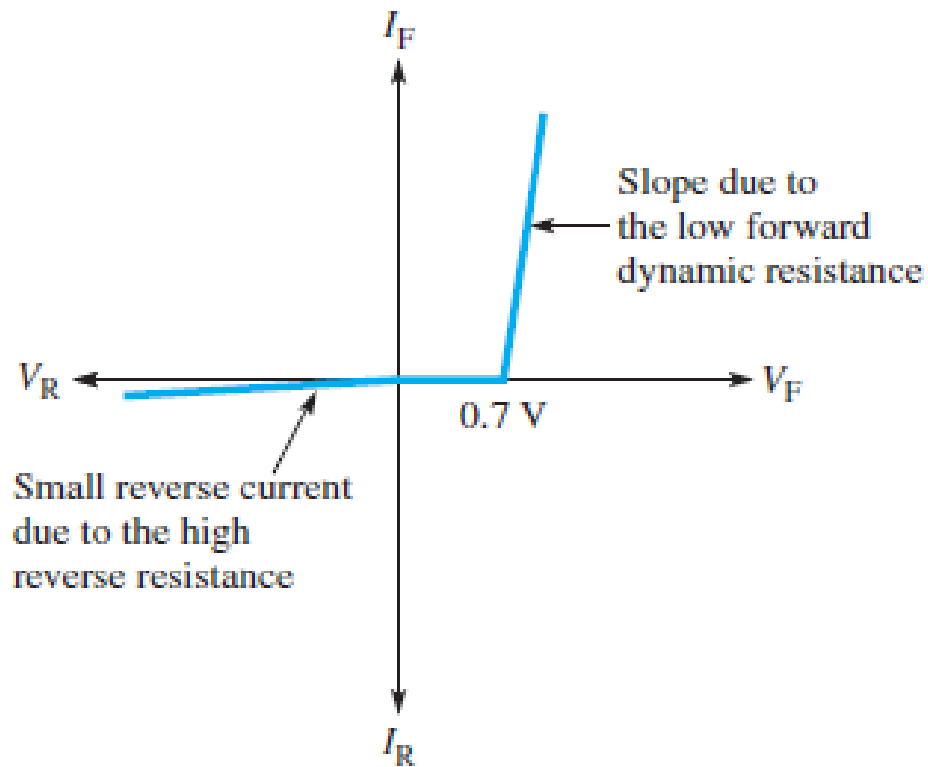




(a) Forward bias



(b) Reverse bias



(c)  $V$ - $I$  characteristic curve

# Problem

- Analyze the circuit shown below using the ideal diode model

